

Appl. No.: 10/608,580
Amndt. Dated: May 19, 2005
Reply to Office Action of: April 21, 2005

Amendments to the Abstract

ABSTRACT OF THE DISCLOSURE

The present invention includes a method of growing a doped glass layer [[films]] suitable for optical applications on a substrate comprising the steps of conveying an organometallic compound of the formula $(R_2SiO)_jM(OR')_k$ $\langle R_2SiO \rangle_j M(OR')_k$ to the substrate and reacting the silica forming substance and the organometallic compound to form the optical layer on the substrate, where M is a metal; R_2 is methyl, ethyl or propyl; R' $\langle R' \rangle$ is methyl, ethyl, n-propyl, n-butyl, isobutyl or s-butyl; j is 1, 2, 3 or 4; and $k=4-j$. The present invention also includes planar optical devices made by the above method. Additionally, the present invention includes an optical fiber made by the above method.